

# NEWS RELEASE

*Hitachi High-Tech*

HITACHI

Hitachi High-Technologies Corporation

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## **Notice of Patent Infringement Lawsuit against FEI Japan**

On July 29, 2010, Hitachi High-Technologies Corporation (TOKYO:8036, Hitachi High-Tech) filed for damages against FEI Japan in the Tokyo District Court, charging infringement related to focused ion beam technology patents held by Hitachi High-Tech.

With respect to Japan FEI, Hitachi High-Tech has filed for an injunction in the Tokyo District Court that will prohibit the production and sale in Japan of the alleged infringing products.\*

\*[http://www.hitachi-hitec.com/global/whatsnew/2009/20091106\\_2.pdf](http://www.hitachi-hitec.com/global/whatsnew/2009/20091106_2.pdf)

### Reference

Notice Regarding Injunction against the Import of FIB/SEM Equipment from FEI Company

<http://www.hitachi-hitec.com/global/whatsnew/2010/nr20100630.pdf>

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